## **IN THE CLAIMS**:

Please cancel Claims 11-18.

- 1. (Original) A fabrication system comprising:
  - a load chamber:
  - a transport chamber connected with said load chamber;
  - a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with each of said film formation chambers; wherein each of said plurality of film formation chambers comprises:

alignment means for allowing positions of a mask and a substrate to be in registry with each other;

substrate holding means;

a plurality of evaporation source holders; and

means for moving said evaporation source holders;

wherein each of said evaporation source holders has containers, said containers being arranged in a longitudinal direction of each of said evaporation source holders, in each of said containers an evaporation material is contained, and means for heating said containers;

wherein said installation chamber comprises:

means for heating said containers previously; and

means for transporting said containers into said evaporation source holders in said film formation chamber;

wherein each of said plurality of film formation chambers connects with a first vacuum exhaust treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state; and

wherein said installation chamber connects with a second vacuum exhaust treatment chamber for allowing an inside of said installation chamber to be in a vacuum state.

- 2. (Original) The vapor deposition system according to claim 1, wherein said substrate holding device overlaps a terminal region, a cut region, or an end portion of the substrate with a mask being sandwiched therebetween.
- 3. (Original) The fabrication system according to claim 1, wherein said substrate holding device and said mask are bonded or welded with each other.
- 4. (Original) The fabrication system according to claim 1, wherein said means for moving said evaporation source holders has a mechanism moving said evaporation source holders in an X-axis direction at a given pitch and, further, a Y-axis direction at another given pitch.
- 5. (Original) The fabrication system according to claim 1, wherein said containers are arranged at equal intervals in each of the evaporation source holder.
- 6. (Original) The fabrication system according to claim 1, wherein the evaporation sources holders is rectangular.
- 7. (Original) A fabrication system comprising:
  - a load chamber;
  - a transport chamber connected with said load chamber;
  - a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with each of said film formation chambers; wherein each of said plurality of film formation chambers comprises:

alignment means for allowing positions of a mask and a substrate to be in registry with each other;

an evaporation source holder; and

means for moving said evaporation source holder;

wherein each of said plurality of film formation chambers connects with a vacuum treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state;

wherein said evaporation source holder has containers, said containers being arranged in a longitudinal direction of said evaporation source holder, in each of said containers an evaporation material is contained, and means for heating said containers; and

wherein said means for moving said evaporation source holder moves said evaporation source holder with a longitudinal direction thereof being set obliquely to a side of the substrate in an X direction or a Y direction of the substrate.

- 8. (Original) The fabrication system according to claim 7, wherein the evaporation source holder is rectangular.
- 9. (Original) A fabrication system comprising:
  - a load chamber;
  - a transport chamber connected with said load chamber;
  - a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with each of said film formation chambers; wherein each of said plurality of film formation chambers comprises:

alignment means for allowing positions of a mask and a substrate to be in registry with each other,

an evaporation source holder; and

means for moving said evaporation source holder;

wherein each of said plurality of film formation chambers connected with a vacuum

exhaust treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state;

wherein said evaporation source holder has containers, said containers being arranged in a longitudinal direction of said evaporation source holder, in each of containers an evaporation material is contained, and means for heating said containers; and

wherein a side of the substrate is set obliquely to a direction in which said evaporation source holder is moved.

- 10. (Original) The fabrication system according to claim 9, wherein the evaporation source holder is rectangular.
- 11-18. (Canceled)
- 19. (Currently Amended) A fabrication system comprising:
  - a load chamber;
  - a transport chamber connected with said load chamber;
  - a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with each of said film formation chambers; wherein each of said plurality of film formation chambers comprises:
- a CCD camera and a stopper for allowing positions of a mask and a substrate to be in registry with each other;
  - a frame;
  - a plurality of evaporation source holders; and
  - a stage for moving said evaporation source holders;

wherein said each of evaporation source holders has containers, said containers being arranged in a longitudinal direction of each of said evaporation source holders, in each of said

containers an evaporation material is contained, and a heater for heating said containers; wherein said installation comprises:

a heater for heating said containers previously; and

a transporting robot for transporting said containers into said evaporation source holders in said film formation chamber;

wherein each of said plurality of film formation chambers connects with a first vacuum exhaust treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state; and

wherein said installation chamber chambers connects with a second vacuum exhaust treatment chamber for allowing an inside of said installation chamber to be in a vacuum state.

20. (Original) The vapor deposition system according to claim 19, wherein said frame overlaps a terminal region, a cut region, or an end portion of the substrate with a mask being sandwiched therebetween.

- 21. (Original) The fabrication system according to claim 19, wherein said frame and said mask are bonded or welded with each other.
- 22. (Original) The fabrication system according to claim 19, wherein said stage has a mechanism moving said evaporation source holders in an X-axis direction at a given pitch and, further, a Y-axis direction at another given pitch.
- 23. (Original) The fabrication system according to claim 19, wherein said containers are arranged at equal intervals in each of said evaporation source holders.
- 24. (Original) The fabrication system according to claim 19, wherein the rectangular evaporation source holders are rectangular.
- 25. (Original) A fabrication system comprising:

- a load chamber;
- a transport chamber connected with said load chamber;
- a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with each of said film formation chambers; wherein each of said plurality of film formation chambers comprises:

a CCD camera and a stopper for allowing positions of a mask and a substrate to be in registry with each other;

an evaporation source holder; and

a stage for moving said evaporation source holder;

wherein each of said plurality of film formation chambers connects with a vacuum treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state;

wherein said evaporation source holder has containers, said containers being arranged in a longitudinal direction of said evaporation source holder, in each of said containers an evaporation material is contained, and a heater for heating said containers; and

wherein said stage moves an evaporation source holder with a longitudinal direction thereof being set obliquely to a side of the substrate in an X direction or a Y direction of the substrate.

- 26. (Original) The fabrication system according to claim 25, wherein the evaporation source holder is rectangular.
- 27. (Original) A fabrication system comprising:
  - a load chamber;
  - a transport chamber connected with said load chamber;

a plurality of film formation chambers connected with said transport chamber; and an installation chamber connected with said film formation chambers; wherein each of said plurality of film formation chambers comprises:

a CCD camera and a stopper for allowing positions of a mask and a substrate to be in registry with each other, an evaporation source holder; and

a stage for moving said evaporation source holder;

wherein each of said plurality of film formation chambers connects with a vacuum exhaust treatment chamber for allowing an inside of each of said film formation chambers to be in a vacuum state;

wherein said evaporation source holder has containers, said containers being arranged in a longitudinal direction of said evaporation source holder, in each of containers an evaporation material is contained, and a heater for heating said containers; and

wherein a side of the substrate is set obliquely to a direction in which said evaporation source holder is moved.

28. (Original) The fabrication system according to claim 27, wherein the evaporation source holder is rectangular.